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Patent US7906414 - Single-shot semiconductor -

Method of manufacturing semiconductor device having Layers,"
1989 Proceedings, Sixth International IEEE VLSI State
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Martin Frank - Publications and patents -

Martin Frank. Research Staff 209 E-MRS 2008 Spring Conference Symposium J. Beyond Silicon Technology: Handbook of Cleaning for Semiconductor Manufacturing:

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Patent US7718517 - Single-shot semiconductor -

A thin film semiconductor workpiece is irradiated with a laser beam to melt and recrystallize target areas of the surface exposed to the laser beam.

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